# Smart metal nanoimprinting solution, tailored to your surface and application.

No Vacuum! No etching! No evaporation!





### **Nanoscale Precision**

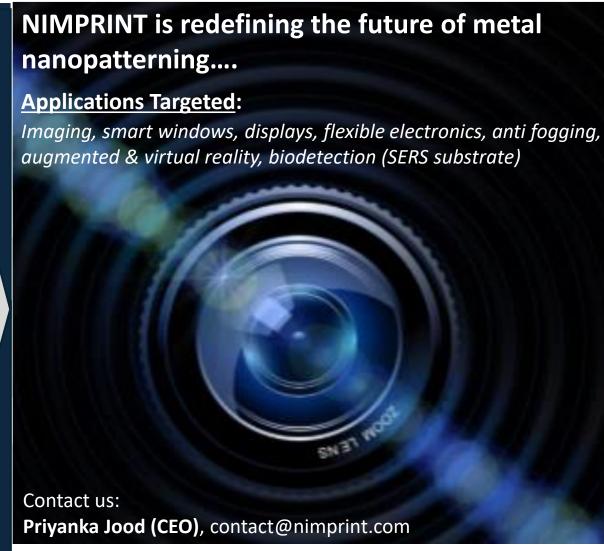
- Ultra low resolutions down to 50 nm.
- Rapid fabrication of complex metal nanostructures on the same substrate → Pixelated polarizer

### **€** Cost-Efficient Manufacturing- Scalable and Sustainable

- Cost-effective production through a streamlined process —
  Dramatically cutting down costs
- Fully compatible with high-throughput manufacturing for large volumes
- No waste- low metal consumption.

## "Direct" Patterning on:

- Sensor windows for superior image clarity
- Polarization beam splitters optimized for compact HMDs/HUDs
- Compatible with flexible and curved surfaces- glass and polymer













# Sample NIMPRINT use cases...



#### Non-Exhaustive

**VISIBLE / SWIR / IR** 

#### 1. Metal Grids

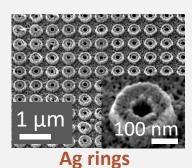
Pixelated polarizer pattern from Au & Ag

Grid size and spacing variation

Adaptable to curved and polymer substrates

### 2. Multiple patterns, One surface

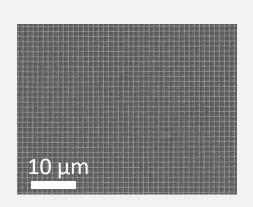




For Biodetection (SERS substrates) & LSPR applications

Imprinting Complex shapes with ease

# **4. Transparent Conductive Surfaces**



Conductive Ag mesh on hard or flexible transparent surfaces

## 3. Metal Coatings and Patterns on Polymers



High reflectivity and adherence of Ag coating and imprints on plastics.

Sustains scratch test.